

NOV 19 2004

Attorney Docket No.: 99CON114P

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Liu, et al.

Serial No.: 09/575,055

Filed: May 19, 2000

For: Method for Selective Fabrication of
High Capacitance Density Areas in a
Low Dielectric Constant Material

Art Unit: 2825

Examiner: Luu, Chuong A.

AMENDMENT AND RESPONSE TO NON-FINAL OFFICE ACTION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir/Madam:

This is in response to the Non-Final Office Action dated July 27, 2004 in the above-referenced patent application. Please enter and consider the following amendments and remarks.